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Chemical incorporation of copper into indium selenide thin-films for processing of CuInSe₂ solar cells

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1 Abstract

A chemical method of incorporating copper into indium selenide thin-films has been investigated, with the goal of creating a precursor structure for conversion into CuInSe₂ layers suitable for solar cell processing. The precursor and converted layers have been investigated with scanning electron microscopy, x-ray diffraction, Raman spectroscopy and x-ray photoelectron spectroscopy. From these measurements, the incorporation of copper into the indium selenide layers is concluded to proceed by an ion-exchange reaction. This reaction results in the formation of a precursor layer with a graded compositional depth-profile containing the crystalline phases In₂Se₃ and Cu_{2-x}Se. Selenization of the precursor layer homogenises the composition and forms chalcopyrite CuInSe₂. These CuInSe₂ layers exhibit a dense microstructure with rough surface morphology, which is ascribed to a non-optimal selenization process. Solar cells with the structure ZnO:Al/i-ZnO/CdS/CuInSe₂/Mo/Glass have been processed from the selenized layers and have exhibited efficiencies of up to 4% under simulated AM1.5 illumination.

2 Introduction

CuInSe₂ (CIS) and its alloys with Ga and S are suitable materials for absorber layers in high-efficiency thin-film solar cells. The highest efficiency cells reported to date (19.5%) were made from copper-poor Cu(In, Ga)Se₂ (CIGS) deposited by the three-stage process [1]. In this vacuum co-evaporation process an (In, Ga)₂Se₃ layer is deposited and then converted into a Cu-rich CIGS layer by exposure to Cu and Se fluxes at high temperature before further evaporation of In, Ga and Se turn the layer Cu-poor [2].

A simpler approach might be advantageous for large-scale production of CIGS solar cells and so methods have been investigated that terminate the second stage before the CIGS layer composition turns Cu-rich [3-6]. In methods where the material deposition is performed at relatively low temperatures, a high temperature anneal is employed to react the resulting bilayer structures [7-10]. Se vapour is often supplied during this annealing stage, in which case it may be referred to as selenization.

Substrate temperature during the material deposition has been shown to have a strong effect on the efficiency of the solar cells produced using two-stage deposition methods [5, 10]. Sequential deposition of In-Se and Cu-Se at room temperature was reported to result in delamination of the precursor during annealing for CIGS layers, however deposition at 100°C was already sufficient to give cells of 13.3% efficiency following selenization at over 500°C. For the depositions performed at 100°C substrate temperature the In-Se and Cu-Se layers were found to have begun to inter-diffuse, whereas room temperature deposition produced a sharp interface

between the layers. Higher deposition temperatures were reported to lead to improved efficiencies, up to 15.5% at 350°C (with selenization at >500°C) and 16.6% at 550°C (without selenization) [5, 10]. For Ga-free CIS devices, when Cu and Se were supplied to an indium selenide precursor layer at 200°C solar cells of 13.7% were reported [8]. These results show that even at low temperatures Cu-Se supply to In(Ga)-Se precursors can result in >10% efficiency CIS-based solar cells, so long as a high temperature selenization treatment is provided.

All of the above-mentioned methods utilized vacuum evaporation, however the deposition temperatures employed in some cases are accessible to chemical methods, such as ion-exchange processes. Ion-exchange reactions, where ions in a thin film exchange places with ions in a solution or gas, are attractive from a technological point of view: they require only simple, low-cost equipment, can proceed at high rates and require relatively low temperatures. In the case of solution-based techniques, since the reaction only occurs at the substrates the baths can be used for an extended period and be easily regenerated. Cation-exchange reactions have been used to create graded structures for thin-film solar cells, including Cu_2S - CdS [11], Cu_xTe - CdTe [12] and $(\text{Cu}_{2-x}, \text{Cd}_x)(\text{In}, \text{Ga})\text{Se}_2$ - $\text{Cu}(\text{In}, \text{Ga})\text{Se}$ [13]. In addition to creating graded structures, ion-exchange reactions can be used to create ternary compounds. For example CuInS_2 has been produced by a low-temperature, gas-based anion-exchange reaction involving metal chloride layers adsorbed from solution [14]. CuInS_2 has also been created in a solution-based cation-exchange reaction by first creating mixed In_2S_3 - Cu_xS nanorods from In_2S_3 nanorods and then annealing them in H_2S to produce CuInS_2 nanorods [15]. Ion-exchange reactions are found to proceed faster at areas where the crystal structure is disorganized, such as at grain boundaries and in materials with a crystal structure incorporating a high density of defects or vacancies. For polycrystalline substrate layers this leads to penetration of the new layer into the substrate layer and the creation of an interpenetrating structure [11]. Such interpenetrating layers formed by ion-exchange methods have similarities in structure to the inter-diffused layers formed by the sequential-deposition vacuum techniques described above.

In this work we used an ion-exchange reaction to incorporate Cu ions from aqueous solution into indium selenide thin-films. It is shown that these precursor layers have a graded composition (Cu/In ratio) throughout the layer thickness that can be homogenised by annealing at high temperature in the presence of selenium vapour. This annealing leads to the formation of chalcopyrite CuInSe_2 suitable for solar cell processing.

3 Experiment

The deposition of indium selenide layers has been demonstrated by several methods, including coevaporation of the elements [16], single-source evaporation of In_2Se_3 [8], sequential electrodeposition of the elements followed by annealing [17], simultaneous electrodeposition of the elements [18], modified chemical bath deposition [19] and spray pyrolysis [20]. In order to provide a high level of control and reproducibility in the indium selenide layers and hence allow the focus of this early-stage work to be maintained on the copper-incorporation process, co-evaporation of elemental indium and selenium was employed in the work reported here. However, any other process, e.g. a non-vacuum chemical deposition process, could equally be applied. The indium selenide layers were deposited onto 25cm² molybdenum-coated soda lime glass substrates by co-evaporation, due to the design of the sample holder an uncoated border of Mo was left around the edge of each substrate.

Copper was incorporated into the indium selenide layers by suspending them in a covered, boiling, aqueous solution of CuSO_4 (0.1M) and acetic acid (0.2M). The acetic acid was required to prevent the formation of $\text{Cu}(\text{OH})_2$ in the solution due to hydrolysis of the Cu ions. After immersion, the precursor layers were rinsed thoroughly in deionised water and dried. Precursor layers were selenized with Se vapour in a two-temperature-zone quartz tube furnace under flowing N_2 . The two zones allowed the temperature of the Se source and hence the Se flux to be controlled separately from the temperature of the substrate. Typically the substrate temperature was ramped in stages to 575°C whilst the Se source was maintained at 400°C . The selenization of some samples was interrupted at 250°C to investigate behaviour of the precursor layers during selenization.

To investigate the role of substrate-coating on Cu incorporation, indium selenide layers grown on Mo/glass, ITO/glass, $\text{SnO}_x\text{:F}$ /glass were employed. Precursor and selenized layers were characterised by stylus profilometry, Scanning Electron Microscopy (SEM), Energy Dispersive X-ray analysis (EDX), X-Ray Diffraction (XRD), Raman spectroscopy and X-ray Photoelectron Spectroscopy (XPS). XRD measurements were made using Cu $K\alpha$ radiation ($\lambda=0.15418\text{nm}$), Raman spectroscopy measurements were made using a He-Ne laser ($\lambda=632.817\text{nm}$) with x10 objective lens and XPS measurements used Al $K\alpha$ radiation ($h\nu=1486.6\text{eV}$) with a 4kV Ar-ion sputter gun to enable depth profile measurements to be performed.

After completion of the absorber formation by selenization some layers were processed into solar cells. These layers were first etched in aqueous potassium cyanide solution (10% w/w) for 30 seconds before deposition of a CdS buffer layer by chemical bath deposition and a ZnO:Al/i-ZnO bilayer-window by RF sputtering. I-V measurements were performed under 1kW/m^2 simulated AM1.5 illumination.

4 Results and Discussion

Indium selenide precursor layers were immersed in the CuSO_4 solution and removed after a time predetermined to give the desired Cu content. For the indium selenide layers used in this work, reaction times of around 1 hour were required to produce precursors with the correct Cu/In ratio for Cu-poor CuInSe_2 . No deposition was observed on the beaker containing the CuSO_4 solution or on the PTFE sample holder and no precipitations were observed in the solution, even after heating and cooling. After the indium selenide precursor layers were removed from the CuSO_4 solution it was observed that their appearance had turned lighter in colour and EDX measurements indicated that Cu had been incorporated into them. At this stage the composition of the precursor layers was non-uniform throughout the EDX electron-beam interaction volume, hence accurate, quantitative composition measurements could not be made with this technique. During immersion in the CuSO_4 solution the Mo exposed around the border of the samples was removed from the substrate and some under-cutting of the edge of the indium selenide layers was observed. This is due to oxidation of the Mo into soluble molybdenum oxide. The appearance and composition of indium selenide layers deposited upon glass, fluorine-doped tin oxide and tin-doped indium oxide substrates remained unchanged after immersion in the CuSO_4 solution. When a small piece of Mo coated glass was suspended in the CuSO_4 solution, limited incorporation of Cu into indium selenide layers deposited on glass substrates was observed. It seems therefore that the presence of Mo activates the Cu-incorporation into the precursor layers. Further investigation is necessary to explain the kinetics of Cu ion migration.

XRD diffractograms are displayed in Figure 1 for precursor layers and selenized samples. All peaks in the diffractogram measured from the as deposited In-Se layer were indexed to hexagonal γ - In_2Se_3 (JCPDS files 40-1407 and 71-0250) and Mo (JCPDS file 42-1120). Following Cu-incorporation into an indium selenide layer, all but one of the In_2Se_3 peaks in the diffractogram weakened in intensity (relative to the Mo (110) peak). The exception is the peak at 27.6° , identified as the (006) peak. Two additional peaks are present in the diffractogram at this stage, one at 26.8° and the other at 44.5° . These peaks are identified as the (111) and (220) peaks of fcc β - Cu_{2-x}Se (JCPDS file 06-0680). The formation of copper selenide with Cu in its monovalent state requires that another species in the bath is oxidised. Since it was observed that the ion-exchange process did not proceed in the absence of Mo it is thought that the reduction of Cu^{2+} ions to Cu^+ is performed by oxidation of either Mo or a Mo oxide, however this has not been confirmed. For the sample selenized to 575°C , all peaks in the diffractogram were indexed to α - CuInSe_2 (JCPDS file 40-1487) and Mo. The chalcopyrite peaks (101), (103), (211) and (105/213) are all observed. No significant preferred orientation is calculated for the diffractogram of this sample and there is no evidence of secondary oxide or binary-selenide phases. When the selenization process was interrupted at 250°C , the measured diffractogram shows a very strong peak at 31.08° , identified as the (006) peak of hexagonal CuSe (JCPDS 49-1457). This indicates that that selenization reaction already begins below 250°C with the reaction of copper selenide and selenium vapour.

Figure 1: XRD Diffractograms for: an indium selenide layer; an indium selenide layer following Cu-incorporation by ion-exchange; a precursor selenized at 250°C and a precursor selenized at 575°C . All peaks in the diffractogram from the sample selenized at 575°C have been indexed to α - CuInSe_2 and Mo.

Raman scattering measurements were performed for identification of the chemical phases in various layers. Raman spectra measured from samples at the same stages of

processing as analysed by XRD are displayed in Figure 2. The Raman spectrum from the as-deposited indium selenide sample exhibits peaks at 151, 205, 228 cm^{-1} , in good agreement with values reported for $\gamma\text{-In}_2\text{Se}_3$ [21]. The Raman spectrum of the indium selenide layer following Cu-incorporation retains the $\gamma\text{-In}_2\text{Se}_3$ peak at 151 cm^{-1} and exhibits an additional peak at 260 cm^{-1} , which is characteristic of copper selenide compounds [22]. This confirms that copper-selenium bonds are being formed during immersion of the indium selenide layers in the CuSO_4 solution. In the Raman spectrum of the sample selenized to 575 $^\circ\text{C}$ peaks are observed at 175, 214 and 227 cm^{-1} . The peak at 175 cm^{-1} is identified as the A1 peak of chalcopyrite CuInSe_2 whilst both of the other two peaks are identified with B2 or E modes [23]. No copper selenide peaks are observed in this spectrum, however, a broad peak was present in the region 153-155 cm^{-1} . The defect chalcopyrite compound CuIn_3Se_5 exhibits an A1 vibrational mode in this frequency range and is identified as a secondary phase in the selenized layers [24]. When the selenization was interrupted at 250 $^\circ\text{C}$, no indium selenide peaks were observed in the Raman spectrum, however two new peaks were present at 263 and 275 cm^{-1} . The peak at 263 cm^{-1} has been associated with CuSe [25], however no reports of an accompanying peak at 275 cm^{-1} could be found in the literature. The diffractogram measured from a sample with similarly interrupted selenization (displayed in Figure 1) indicates the presence of both CuSe and In_2Se_3 phases, therefore the absence of the indium selenide peaks in the Raman spectrum is attributed to a phase separation through the depth of the layer, leading to the Raman signal being generated solely within the copper selenide surface layer.

Figure 2: Raman spectra for: an indium selenide layer; an indium selenide layer following Cu-incorporation by ion-exchange; a precursor selenized at 250 $^\circ\text{C}$ and a precursor selenized at 575 $^\circ\text{C}$. The Raman spectrum for the sample selenized at 575 $^\circ\text{C}$ contains three peaks characteristic of CuInSe_2 and a broad peak around 154 cm^{-1} that indicates the presence of CuIn_3Se_5 .

Depth-profile XPS measurements displayed in Figure 3 for an indium selenide layer following Cu-incorporation show that it has a graded composition, with peak copper concentration corresponding to minimum In concentration. The Se concentration decreases within the copper containing region of the layer, relative to its value in copper-free region. This is consistent with the formation of Cu_{2-x}Se as it has a higher metal-to-chalcogen ratio than In_2Se_3 . The depth-profile of the selenized sample is broadly homogenised compared to the un-selenized sample. However, an increase in the concentration of indium throughout the depth of the sample is observed, as is a possible accumulation of Cu at the back-contact interface. EDX measurements on this selenized sample indicated a Cu:In:Se composition of 21.3:30.9:47.8 at%. Oxygen impurities were not detected in either sample beyond the first points measured at the surface.

Figure 3: XPS depth-profiles of an indium selenide layer following copper incorporation by ion-exchange (left) and a selenized copper-poor layer (right). Data are not quantitative and indicate only the distribution of the elements throughout the depth of the layers.

The secondary electron images displayed in Figure 4 for indium selenide layers before (left) and after (middle) Cu-incorporation show no significant change in layer morphology, which is consistent with morphology transfer observed in ion-exchange processes [15]. No cracks are observed to form during Cu-incorporation. The secondary electron image displayed in Figure 4 for a selenized layer (right) shows that the layer has re-crystallised with a rough surface. Cross-section secondary electron images displayed in Figure 5 for an indium selenide layer following Cu-incorporation (left) and a selenized Cu-poor layer (right) show that pronounced changes in morphology and grain structure occur during selenization. The selenized copper-poor CuInSe_2 layers exhibits a dense microstructure and the rough surface morphology is again apparent. No change in the thickness of the layers after Cu-incorporation could be measured by stylus profilometry, in this case limiting changes in thickness to less than 30nm. After selenization an average thickness increase of approximately 12% was measured.

Figure 4: Secondary electron images of as-deposited indium selenide (left), indium selenide following Cu-incorporation by ion-exchange (middle) and a selenized layer (right).

Figure 5: Secondary electron cross-section images of an indium selenide layer following copper incorporation by ion-exchange (left) and a selenized layer (right).

We believe structural properties and crystal structure of indium selenide layers play an important role in the ion exchange process. γ - In_2Se_3 possesses a defect-wurtzite structure wherein one third of the cation sites are vacant [16]. This crystal structure presents three possible locations for the incorporation of Cu ions into a γ - In_2Se_3 layer: as interstitials, on vacant cation sites or on In sites. Incorporation onto an In site requires the removal of the In ion, either to one of the other sites or to the solution. Whilst the precise reaction steps involved in the incorporation of copper into the indium selenide layers remain unclear, from consideration of the data reported here the proposed net mechanism is an ion-exchange reaction according to:

This reaction proceeds from the surface of the indium selenide layer and therefore results in a layer of β - Cu_{2-x}Se over the γ - In_2Se_3 , with the Cu_{2-x}Se most probably penetrating more rapidly into the In_2Se_3 layer along grain boundaries, as has been observed for other ion-exchange reactions involving polycrystalline layers [11]. Cu_{2-x}Se exhibits high cationic conductivity and high In diffusion coefficients have been specifically observed in Cu_{2-x}Se [26], allowing the ion-exchange reaction to continue after the In_2Se_3 surface is covered with Cu_{2-x}Se . Removal of the precursor layer from the hot CuSO_4 solution quenches the ion-exchange reaction, hence the Cu_{2-x}Se surface layer should contain a graded concentration of indium ions that were diffusing towards the surface. The diffuse boundary between the copper and indium selenide layers that is observed in the XPS data is attributed in part to these In atoms and in part to interpenetration of the layers along grain boundaries.

β - Cu_{2-x}Se and γ - In_2Se_3 have been observed to react directly to form CuInSe_2 at temperatures $>425^\circ\text{C}$ in investigations of stacked selenide thin-films and diffusion

couples [26, 27]. However, the Raman spectra and XRD diffractograms reported here for partially selenized samples indicate a change in the copper selenide phase from Cu_{2-x}Se to CuSe during selenization of our samples. EDX measurements on Cu_{2-x}Se layers heated to around 250°C in our tube furnace and then cooled to room temperature confirmed that the Cu:Se ratio decreases from 1.7:1 to 1:1. Based on these observations it is concluded that the copper selenide layer formed by ion-exchange reacts with elemental Se during heating according to the reaction:

Therefore, the actual CuInSe_2 formation reaction that occurs is considered to be:

This reaction has been observed directly by high temperature *in situ* XRD measurements during annealing studies of evaporated bilayers [28]. The incorporation and subsequent loss of selenium during these two reactions should result in first an increase and then a decrease in the volume of the layer. Indeed, stylus profilometry measurements on a sample for which selenization was interrupted at 250°C show a thickness increase of approximately 30% (c.f. 12% for layers selenized to 575°C). The decrease in thickness that must therefore occur as the selenization proceeds to higher temperatures is identified as a cause of the roughness of the selenized layers [29].

Solar cells processed from selenized precursor layers have exhibited efficiencies of up to 4% and the J-V curve of such a solar cell is shown in Figure 6. This cell is typical of solar cells processed during this work in having low open circuit voltage and low shunt resistance. The relatively low device efficiency that has been achieved is considered to arise in large part from the rough morphology of the absorber layers produced so far by this process. Since the morphology of the absorber layer is determined during the selenization process, optimisation of this stage is required to improve the performance of the devices processed from these absorbers. The use of rapid thermal processing (RTP) in place of tube-furnace annealing has been shown to lead to improvements in the morphology of CuInSe_2 produced from stacked elemental layers of Cu, In and Se [30]. Similar benefits might be found for the precursors developed in this work, resulting in better quality layers and solar cells.

Figure 6: J-V curve for a CuInSe_2 solar cell processed from a precursor layer produced by ion-exchange incorporation of Cu into an indium selenide layer.

5 Conclusion and prospects

The chemical incorporation of Cu into In_2Se_3 layers by ion-exchange from aqueous solution is reported. This process results in thin films with a graded compositional depth-profile containing the crystalline phases $\beta\text{-Cu}_{2-x}\text{Se}$ and $\gamma\text{-In}_2\text{Se}_3$. Annealing these layers in the presence of Se vapour is shown to homogenise the compositional depth-profile of the layers and to form chalcopyrite CuInSe_2 . The ion-exchange solution that was employed was found to be destructive to the exposed areas of the Mo back-contact, however attempts to use alternative back-contact materials resulted in no incorporation of Cu into the In_2Se_3 layers, indicating that Mo activates the Cu-incorporation process.

Solar cells processed from CuInSe_2 layers produced in this early-stage work showed encouraging characteristics, with efficiencies of up to 4% under 1 kW/m^2 simulated AM1.5 illumination. However, the devices were characterised by low open circuit voltages and low shunt resistances, attributed to the rough morphology of the layers. Optimization of the selenization process is required to improve the morphology of the absorber layers and this optimization may require the application of rapid thermal processing. The suitability of the absorber layers for use in solar cells could also be increased by incorporation of Ga into the precursor and work to investigate the behaviour of $(\text{In}, \text{Ga})_2\text{Se}_3$ precursor layers during the ion-exchange process is required.

These results demonstrate a potential simple, low-temperature route to the formation of a precursor structure suitable for conversion into CuInSe_2 thin-films for solar cell processing. Co-evaporated indium selenide layers were used during this work in the interest of control, however, to fully realise a simple production method for CuInSe_2 -based solar cells it is desirable to employ an alternative deposition method. Several non-vacuum methods have been demonstrated in the literature for the deposition of indium selenide and so long as sufficient homogeneity can be achieved there is no reason why they could not be used with the ion-exchange process reported here. Higher rates of Cu incorporation might be possible with changes to the solution composition, which would be attractive for high-speed processing of layers. Results of further studies on this subject will be reported elsewhere in future.

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